



63-23-05

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Patrick M. Martin, Matthew Lassiter, Darren Taylor,
Michael Cangemi and Eric Poortinga
Serial No. : 10/658,039
Filing Date : September 9, 2003
Title: : PHOTOMASK HAVING AN INTERNAL
SUBSTANTIALLY TRANSPARENT ETCH STOP LAYER

Customer No. : 1912
Group Art Unit : 1756
Attorney Docket No. : 67493/63
Examiner : To Be Assigned

"Express Mail" mailing label No.	EL996374783US
Date of Deposit:	March 22, 2005
I hereby certify that this paper or fee is being deposited with the United States Postal Service "Express Mail" service under 37 CFR 1.10 on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.	
Name:	Gerri Renna
Signature:	

STATUS INQUIRY

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Applicant respectfully inquires as to the status of the above-identified application. The last correspondence received from the U.S. Patent Office was our Return Receipt Postcard dated February 18, 2005 acknowledging receipt of an Information Disclosure Statement, Form PTO/SB/08A and four Japanese Disclosures. To date, we have not received any further correspondence.

Respectfully submitted,

AMSTER, ROTHSTEIN & EBENSTEIN LLP
Attorneys for Applicant
90 Park Avenue
New York, NY 10016
(212) 336-8000

By:
Charles R. Macedo
Registration No. 32,781

Dated: New York, New York
March 22, 2005